# OPTIMIZATION OF IRIDIUM OXY-HYDROXIDE FILMS FOR PH MONITORING OF UNDERGROUND COMPONENTS OF NUCLEAR REPOSITORIES

Romain Rodrigues<sup>1</sup>, Ioannis Ignatiadis<sup>1</sup>, Johan Bertrand<sup>2</sup>, Stéphanie Betelu<sup>1\*</sup>

- 1: BRGM (French Geological Survey), Orléans, France (\*s.betelu@brgm.fr)
- <sup>2</sup>: ANDRA (French National Radioactive Waste Management Agency), Châtenay-Malabry, France

# CONFERENCE

13-16 June 2022 - Nancy (France)

ON CLAYS IN NATURAL AND ENGINEERED BARRIERS FOR RADIOACTIVE WASTE CONFINEMENT

#### Introduction

The development of robust all-solid pH sensors, which do not necessitate any maintenance, is required for the long-term monitoring of the pore water of clay-based disposal systems.

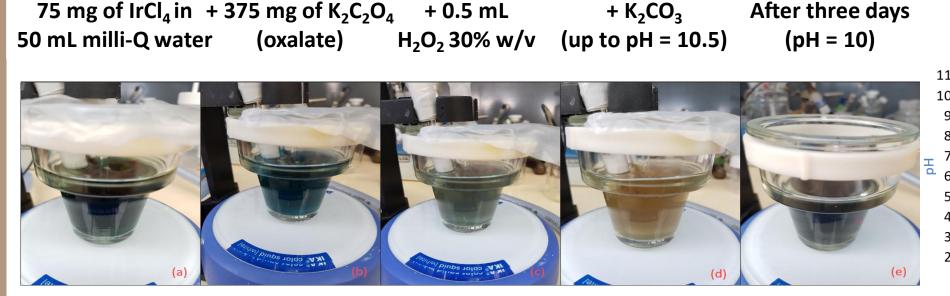
Due to their high stability, corrosion resistance and reversible redox properties, iridium oxy-hydroxides (IrOx) are widely investigated for pH sensing and can be regarded for pH monitoring of underground components of nuclear repositories.

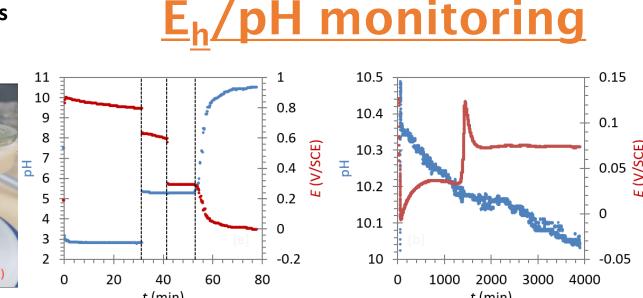
This work aims at investigating and optimizing the IrOx electrodeposition process for accurate pH measurements with the specific constraints related to on-site conditions.

#### Materials and methods

#### Preparation of Ir<sup>IV/III</sup>-based solutions

Based on the protocol proposed first by Yamanaka [1]

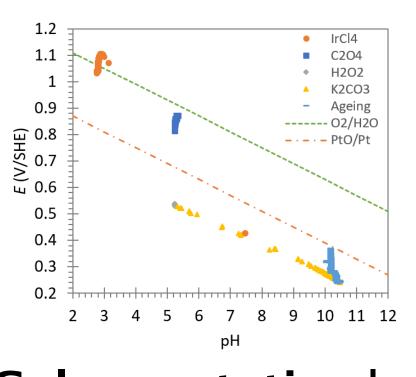


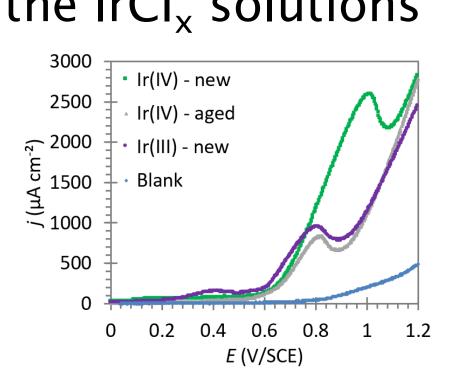


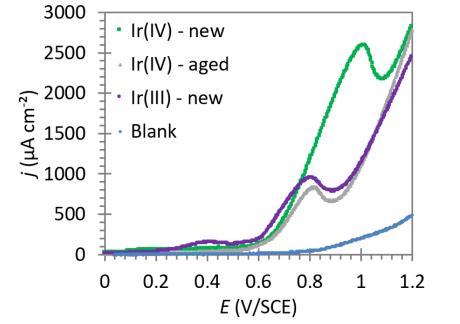
#### Investigation of the electrodeposition mechanism

Use of electrochemical quartz crystal microbalance (EQCM) to determine the variation in mass during experiments

- Characterization of the blank solution
- Characterization of the IrCl<sub>x</sub> solutions

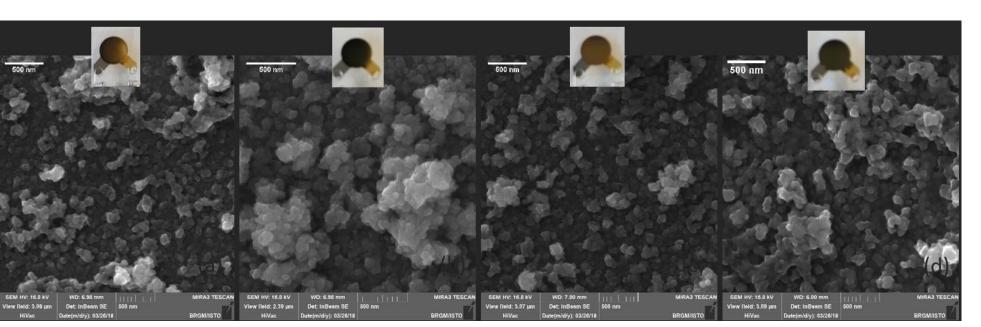








- Potentiostatic electrodeposition ( $E_{constant}$ )
- Electrodeposition by cyclic voltammetry
- Characterization of the IrOx films

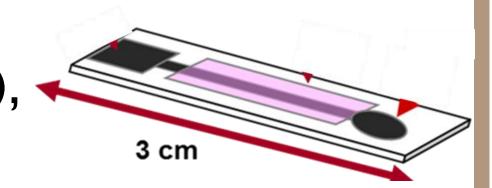




Sauerbrey equation:

#### III. Determination of the sensitivity of IrOx films

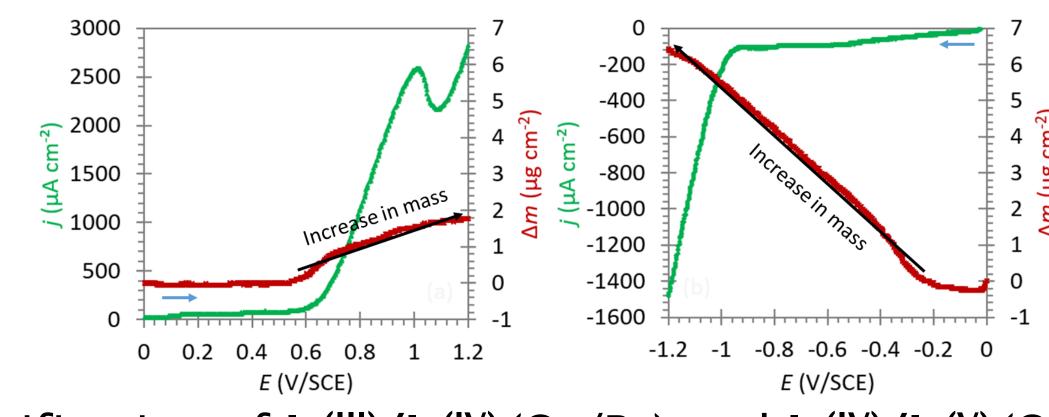
Electrodeposition of IrOx films on Carbon-based Screen-Printed Electrodes (SPEs), as already performed in [2] for Sb-based SPEs



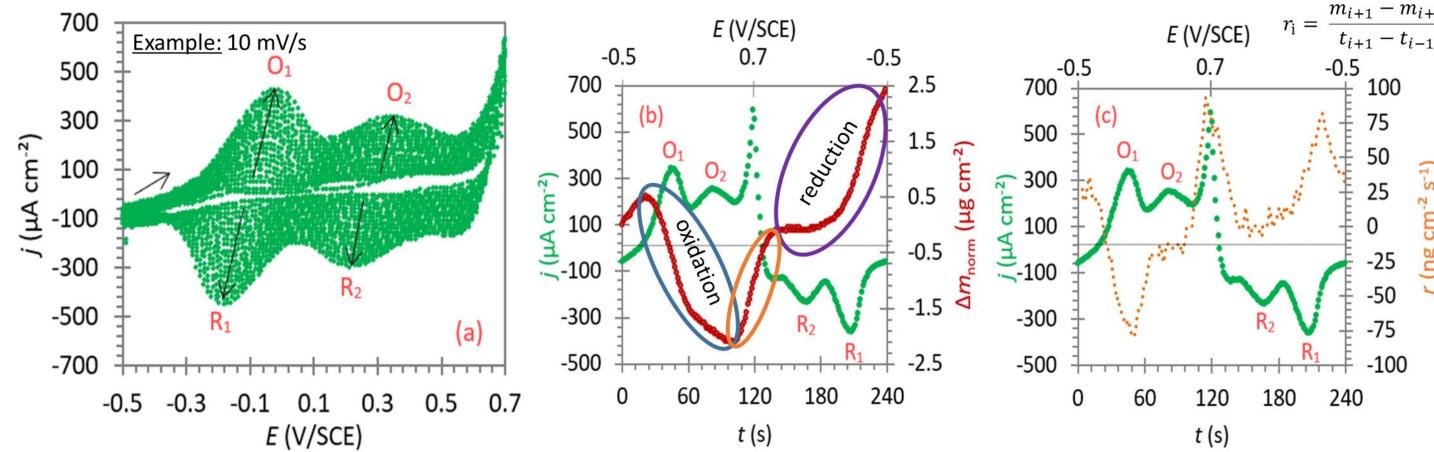
- Same electrodeposition methods as described above
- Potentiometric measurements in pH buffers 4-12 at 25 °C, under atmosphere and in glove box (GB, pO<sub>2</sub> =  $10^{-6}$  atm)

#### Results

- **Electrodeposition mechanism**
- Presence of many electroactive species in the solutions
- Electrodeposition mainly observed in parallel to water oxidation (E > 0.6 V/SCE)/oxygen reduction (E < 0 V/SCE)



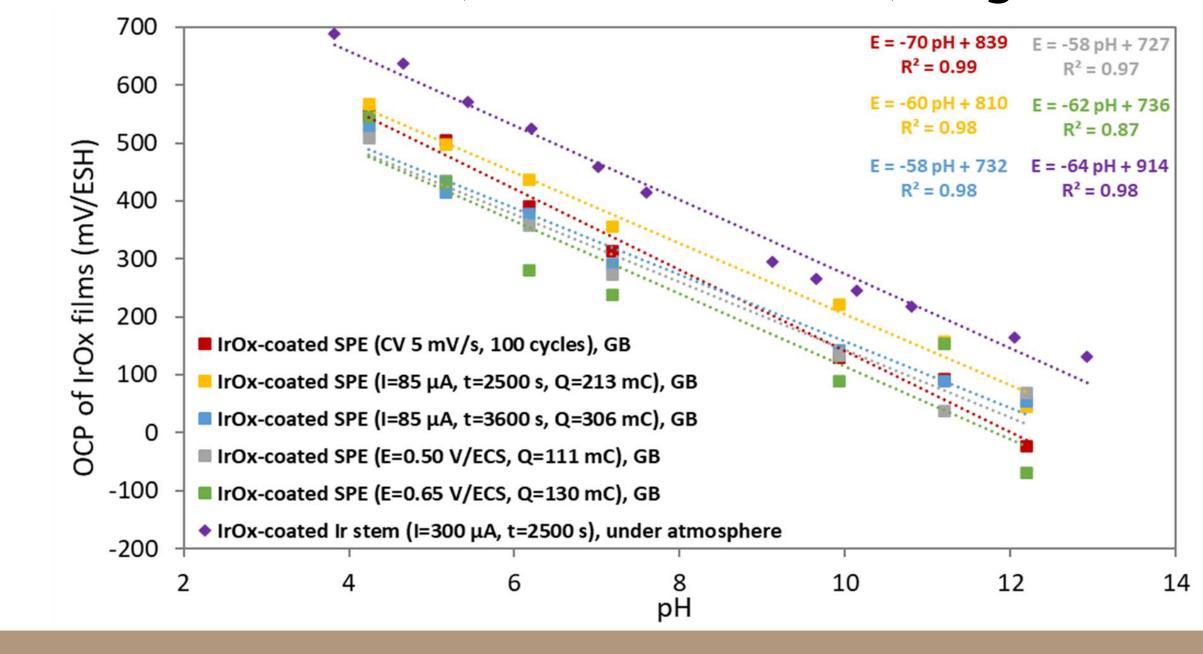
Identification of  $Ir^{(III)}/Ir^{(IV)}(O_1/R_1)$  and  $Ir^{(IV)}/Ir^{(V)}(O_2/R_2)$  redox couples on IrOx films during cyclic voltammetry



Loss in mass during their oxidation ( $O_1$  and  $O_2$ ), and gain in mass during their reduction ( $R_1$  and  $R_2$ )

#### II. Sensitivity of IrOx films for pH monitoring

- Higher sensitivity with galvanostatic electrodeposition or cyclic voltammetry (slopes between -60 and -70 mV/pH)
- Low corrosion rates (EIS measurements) → good stability



## Conclusions and perspectives

- 1. Electrodeposition by cyclic voltammetry involves several electroactive Ir and Ir species. Mass variations occurs mainly in parallel to water oxidation and oxygen reduction reactions.
- 2. Variation during cyclic voltammetry suggests deprotonation during oxidation of IrOx films and (re-)protonation or hydroxylation during their reduction
- 3. IrOx films properties (hydration, oxidation state) can be tuned after electrodeposition, irrespective of the method of electrodeposition
- 4. IrOx films appear stable and can exhibit a high sensitivity (60-70 mV/pH), showing their interest and ability for long-term pH monitoring

Further work is in progress to demonstrate the robustness of IrOx-based sensors in situ over a long period

### References/Acknowledgments

This work was funded by a BRGM-ANDRA partnership; CAPTANDRA project

[1] K. Yamanaka, Jpn. J. Appl. Phys. 28 (1989) 632-637.

[2] J. Daoudi, S. Betelu, T. Tzedakis, J. Bertrand, I. Ignatiadis. Sensors 17 (2017) 1372.

[3] R. Rodrigues, J. Bertrand, I. Ignatiadis, S. Betelu. Article on the electrodeposition mechanism in preparation





